Exciton-related electroluminescence from ZnO nanowire light-emitting diodes

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(Received 8 May 2009; accepted 29 May 2009; published online 19 June 2009)

The authors study the microscopic origin of the electroluminescence from zinc oxide (ZnO) nanowire light-emitting diodes (LEDs) fabricated on a heavily doped p-type silicon (p-Si) substrate. By comparing the low-temperature photoluminescence and electroluminescence of a single nanowire LED, bound- and free-exciton related recombination processes, together with their longitudinal-optical phonon replicas, can be identified as the origin of both electroluminescence and photoluminescence. © 2009 American Institute of Physics. [DOI: 10.1063/1.3157274]

Semiconductor nanowires offer interesting possibilities in the area of photonics.1–4 Nanowires are naturally anisotropic structures which, given certain dimensional constraints, can support waveguide modes and even lasing.5 An even more intriguing prospect is that of combining widely different semiconductor materials, such as direct band-gap materials and silicon, without the need for wafer bonding technology.6–8 In particular, we have recently demonstrated the fabrication of nanowire light-emitting diodes (LEDs) on a heavily-doped p-type silicon (p-Si) substrate, using nanowires of the wide-band-gap semiconductor zinc oxide (ZnO). ZnO is a material well suited for the development of ultraviolet (UV) optoelectronic devices9–12 due to its large exciton binding energy.11,13 Using high-temperature vapor-liquid-solid growth techniques, nontoxic and relatively inexpensive routes for the fabrication of high-quality ZnO nanowires have been demonstrated in recent years.14–16 These ZnO nanowires have been shown to exhibit carrier densities of about N=1017 cm−3 at room temperature and distinct bound exciton-related photoluminescence (PL) emission lines at liquid-helium temperatures.16,17 Despite this, the evidence of excitonic recombination in electroluminescent ZnO devices has been indirect, and inferred from a peak emission energy smaller than what one would expect for band-to-band recombination.18–21

The main drawback of the ZnO material system is the lack of reproducible, stable, high-quality p-type doping with a reasonable concentration, which is required for most optoelectronic applications.15 In our recent demonstration, the heterojunction is formed between the n-ZnO nanowire and a p-Si substrate.12 If the p-Si native oxide is not removed before the fabrication of the nanowire devices, it acts as a tunnel barrier between the two semiconductors.10,11 With an applied external bias, holes can tunnel from the valence band of the p-Si into the valence band of the ZnO nanowire. For such devices, UV electroluminescence (EL) has been observed at room temperature with the output intensity showing an almost linear dependence on the current flowing through the nanowire LED. In this paper, we study the microscopic processes that are involved in the radiative recombination of electrons and holes in n-ZnO/p-Si nanowire LEDs.

Details about the synthesis of the ZnO nanowires have been presented elsewhere.15 In short, single crystalline ZnO nanowires were synthesized by a vapor-liquid-solid growth technique in a horizontal tube furnace at temperatures between 1000 and 1350 °C. The as-grown wires are typically 10–30 μm long and 100–350 nm in diameter. The nanowire LEDs were fabricated with a method similar to that described in Ref. 12 (the differences are described below). After growth, the nanowires were dispersed onto a heavily doped p-type silicon substrate (~1019 cm−3) covered with a native layer of SiO2. An 80 nm thick film of hydrogen silsesquioxane (HSQ, also known as spin-on glass, obtained as FOx-12 from Dow Corning) was then spun onto the substrate, resulting in a film profile in which the HSQ film is thinner on top of the nanowires than in the spaces between them. After cross-linking the HSQ with an electron beam writer (we use a dose of 300 μC/cm2), the film was thinned down by ~35 nm by reactive ion etching, which results in the top surfaces of the nanowires being exposed but not the silicon substrate. Finally, Ti(10 nm)/Au(100 nm) contacts were deposited with an electron beam evaporator. The schematics of the nanowire LEDs are shown in Fig. 1.

The samples were mounted inside a helium flow cryostat equipped with a temperature controller and an optical port. The external voltage was applied between the top metallic

FIG. 1. (Color online) Schematics of the n-ZnO/p-Si nanowire LEDs. (a) Top view, (b) cross-sectional view.

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can be attributed to the radiative recombination of the C exciton in its ground state. The C exciton emission is only allowed for electric fields parallel to the c-axis of ZnO and therefore can be expected to contribute to the PL spectrum of our dispersed nanowires more strongly than to the EL spectrum.

In general, the PL and EL spectra present similar structure, with the EL spectrum shifted to lower energies by about 12 meV and also exhibiting slightly broader emission lines, as determined by the full width at half maximum (FWHM). In particular, the main D0X band has a FWHM of 4 meV in the PL spectrum and 7 meV in the EL spectrum. This difference may be accounted for by a higher local temperature for the EL due to electrical heating, which can be supported by two separate arguments. The 12 meV redshift in the EL spectrum corresponds to a temperature increase of about 50 ± 30 K (Ref. 25), assuming a purely thermal effect. In addition, the relative intensities of the FX shoulder and the main D0X band are different: in the PL spectrum, we find a ratio of I_{FX}/I_{D0X} = 0.39, while in the EL spectrum, the ratio is I_{FX}/I_{D0X} = 0.39, i.e., in EL a significantly higher fraction of excitons is thermally activated from the donor localization centers. More specifically, by measuring the PL spectrum of a nanowire and calculating the ratio I_{FX}/I_{D0X} as a function of temperature, we find that I_{FX}/I_{D0X} = 0.39 corresponds to a temperature of approximately 60 K. Thus, we conclude that the local temperature in our LED, placed on a substrate at 10 K, can be increased by approximately 50 K under a 6 V, 50 μA (300 μW) bias.

The PL and EL spectra of the single nanowire LED at higher temperatures reveal a continuous increase of the intensities of the FX lines together with their LO phonon replica, as can be seen from the results shown in Fig. 3.

FIG. 3. PL and EL spectra of a ZnO nanowire LED recorded at temperatures between 100 and 200 K. The main emission lines are assigned to the FX and its LO phonon replica (1 LO and 2 LO).
In contrast, in the EL spectra at $T > 150$ K the FX band shows a comparable intensity with its 1 LO side band which is distinctly more pronounced than in the PL spectra. This results in a slight redshift of the overall EL emission band at 200 K when compared to the PL emission taken at the nominally same temperature. The difference between the PL and EL spectra is most likely due to the current flowing through the nanowire LED, which we expect to cause greater heating compared to the PL measurements, as already observed for $T = 6$ K. Still, our results clearly demonstrate that the EL from $n$-ZnO/p-Si nanowire LED stems from excitonic recombination processes.

In summary, at $T = 6$ K, D0X emission dominates the EL, whereas at temperatures above 150 K, the FX, together with its LO phonon replica, are responsible for light emission. In conclusion, we have studied the microscopic origin of EL from ZnO nanowire LEDs. We have found clear evidence for exciton-related emission processes that dominate the near band-edge emission of the nanowire LED at temperatures between 6 and 200 K. At low temperatures, donor bound exciton-related emission lines are observed both in PL and EL. We conclude that the nanowire is heated by about 50 K during the electrical operation with 300 $\mu$W of electrical power. Still, due to the relatively large binding energies of the exciton complexes in ZnO, efficient excitonic recombination processes persist. At higher temperatures, the FX emission together, with its first LO phonon replica, dominated the EL emission spectrum. Our results demonstrate that $n$-ZnO/p-Si nanowire LED operate with efficient excitonic recombination processes and should provide high internal quantum efficiencies leaving the tunnel injection of holes into the nanowires as the main limiting factor.

The authors acknowledge the detailed and helpful comments of an anonymous reviewer. This work was supported by the National Science Foundation Nanoscale Science and Engineering Center (NSEC) under Contract No. NSF/PHY 06-46094 and by the German Research Foundation through Grant Nos. VO1265/3, VO1265/4-1.2, and Ro1198/7-1.2. The support of the Center for Nanoscale Systems (CNS) at Harvard University is also gratefully acknowledged. Harvard-CNS is a member of the National Nanotechnology Infrastructure Network (NNIN).